

Spin-electricity conversion induced by spin pumping into topological insulators

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Phys.Rev.Lett. **113**, 196601 (2014)



Spin injection into “bulk-insulating” topological insulators

PRL **113**, 196601 (2014)

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7 NOVEMBER 2014

Spin-Electricity Conversion Induced by Spin Injection into Topological Insulators

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theory



TI sample

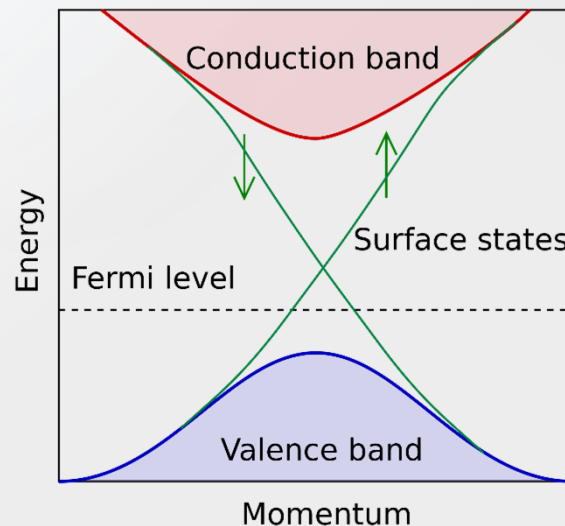
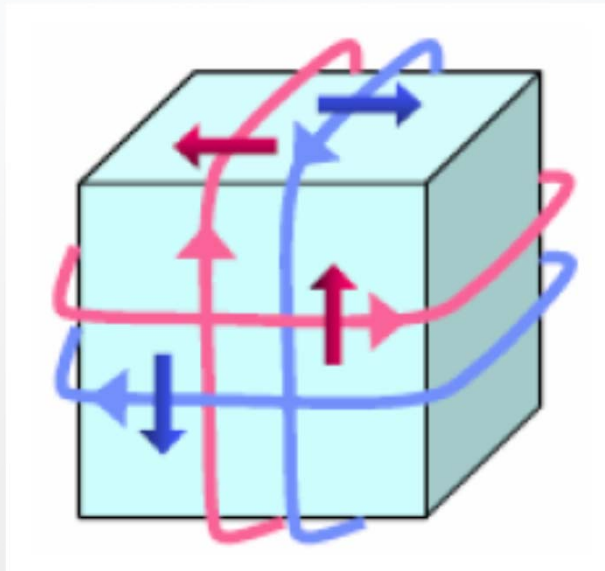


boss

arXiv:1312.7091 (2013)
Phys.Rev.Lett. **113**, 196601 (2014)

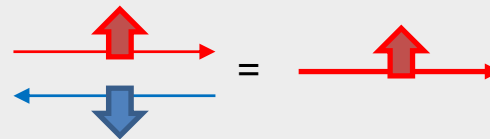
TI is a promising material for spintronics application

Topological Insulator (TI)



Surface: metal
Interior: Insulator

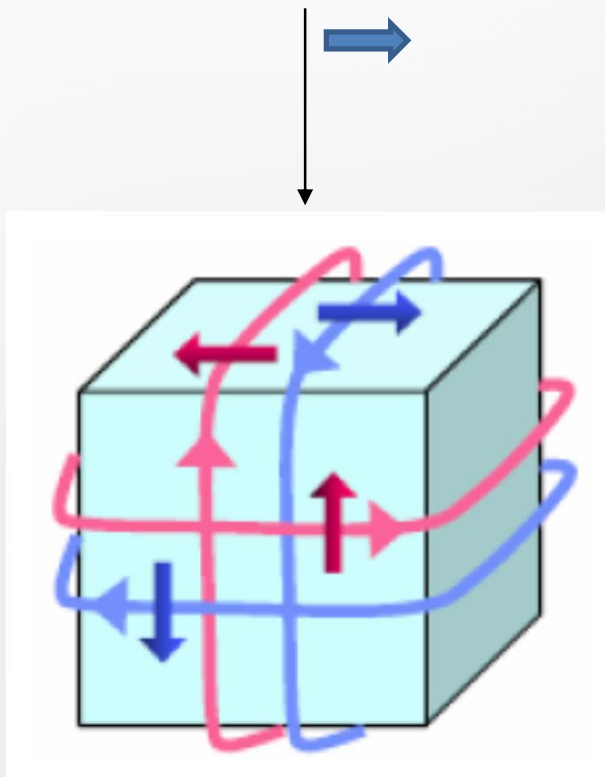
- (1) spin current $\neq 0$
electric current = 0



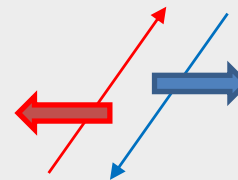
- (2) spin-momentum locking
- (3) surface property determined by bulk property

Spin injection into surface states of topological insulators

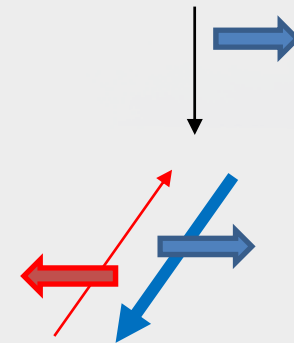
spin injection



spin injection



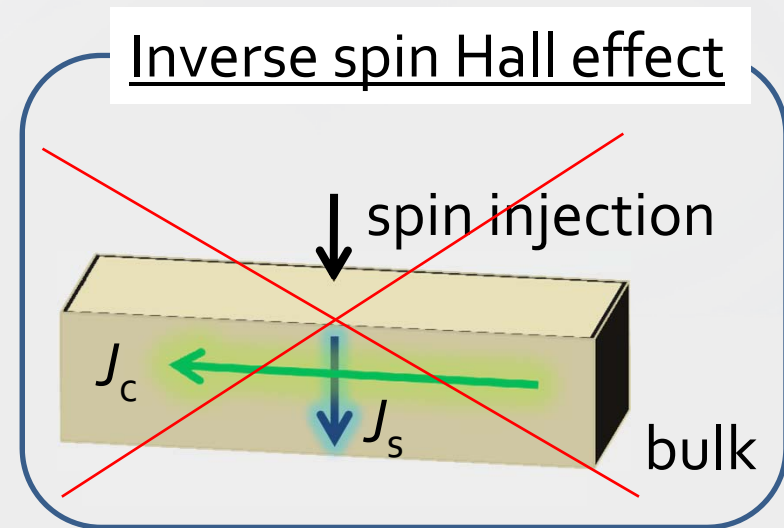
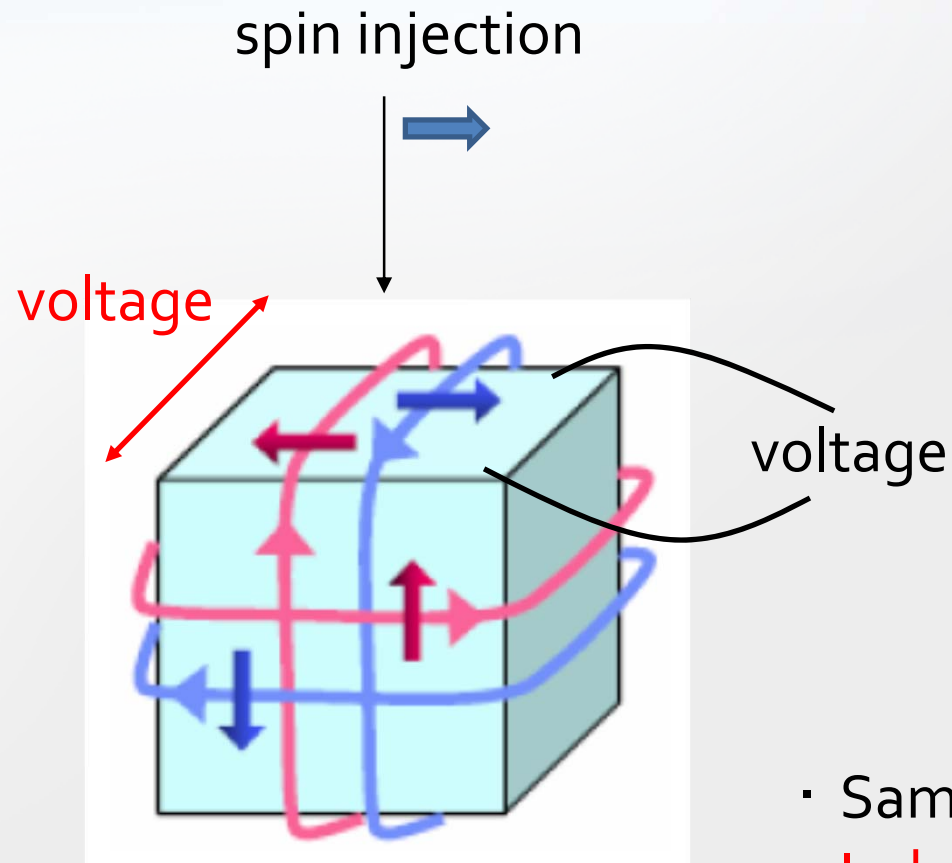
Electric current = 0



$\neq 0$

Electric current induced by spin injection

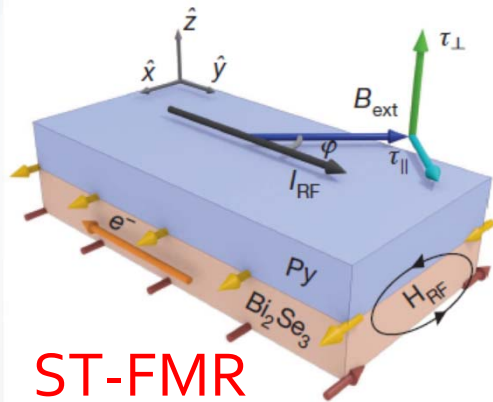
Spin-electricity conversion induced by spin injection



- Same symmetry as ISHE
- Induced by spin-momentum locking
(in principle, perfect conversion)

Some trials for spintronics application of TI

A.R.Mellnik, et al. Nature 511, 449-451 (2014)



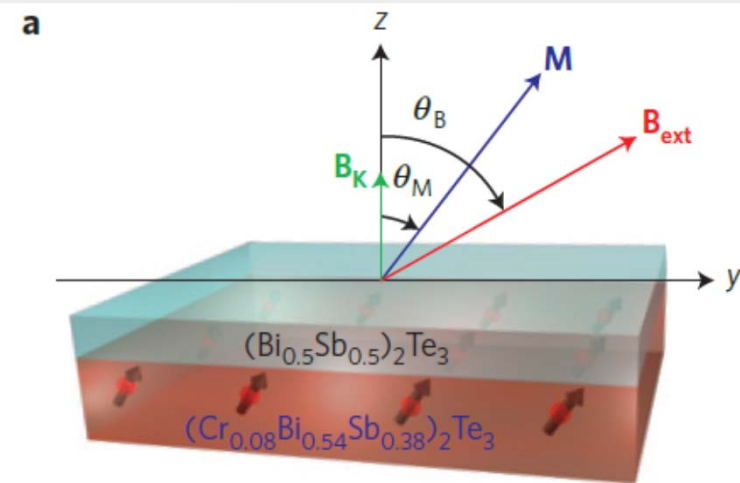
ST-FMR

Parameter	Bi ₂ Se ₃ (this work)
$\theta_{\parallel}$	2.0–3.5
$\sigma_{S,\parallel}$	1.1–2.0

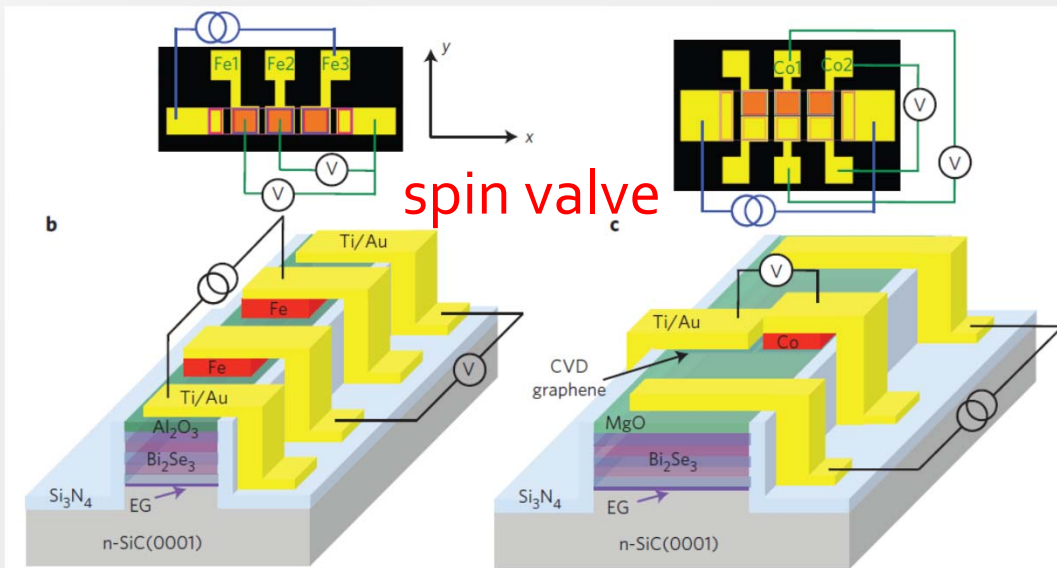
Hall angle > 1

Y. Fan, et al. Nature Mat. 13, 699-704 (2014)

Magnetization switching



C.H.Li, et al. Nature Nano. 9, 218-224 (2014)



spin valve

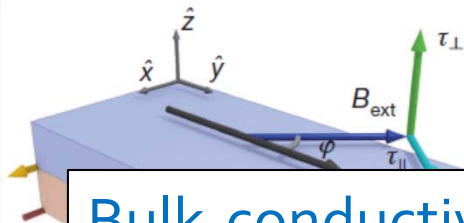
electric means

Bulk insulating
⇒ tiny electric current in TI

Some trials for spintronics application of TI

A.R.Mellnik, et al. Nature 511, 449-451 (2014)

Y. Fan, et al. Nature Mat. 13, 699-704 (2014)



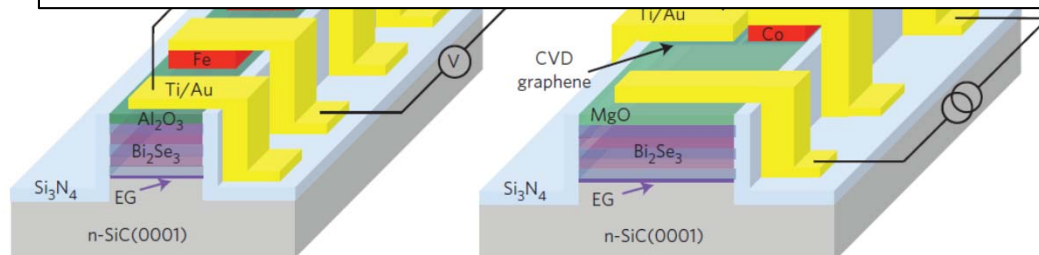
Parameter	Bi_2Se_3 (this work)
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Magnetization switching

Bulk-conductive TI $\Rightarrow$ contaminated by bulk carriers
 Bulk-insulating TI $\Rightarrow$ not-efficient spin transfer (Res. mismatch)

How can we observe "pure" surface spin transport of TIs ?

- spin pumping : free from impedance mismatch (K.Ando 2011)
- one more idea to minimize bulk-carrier contribution



Bulk insulating
 $\Rightarrow$ tiny electric current in TI

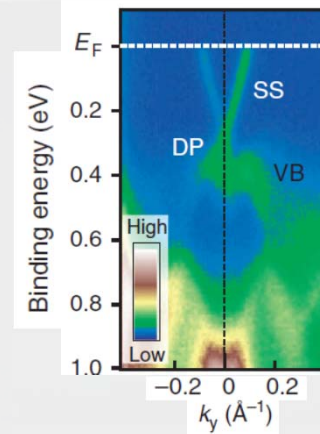
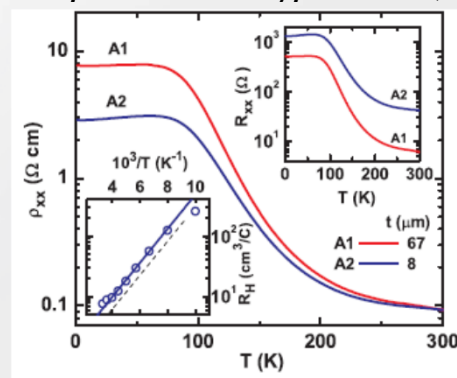
Our experimental setup: Use of “Bulk form” topological insulators

T.Arakane, et al. Nat. Commun. 3, 636 (2011)

Bulk-carrier compensated TIs:

$\text{Bi}_{1.5}\text{Sb}_{0.5}\text{Te}_{1.7}\text{Se}_{1.3}$, BiSbTeSe_2 ,
Sn-doped $\text{Bi}_2\text{Te}_2\text{Se}$

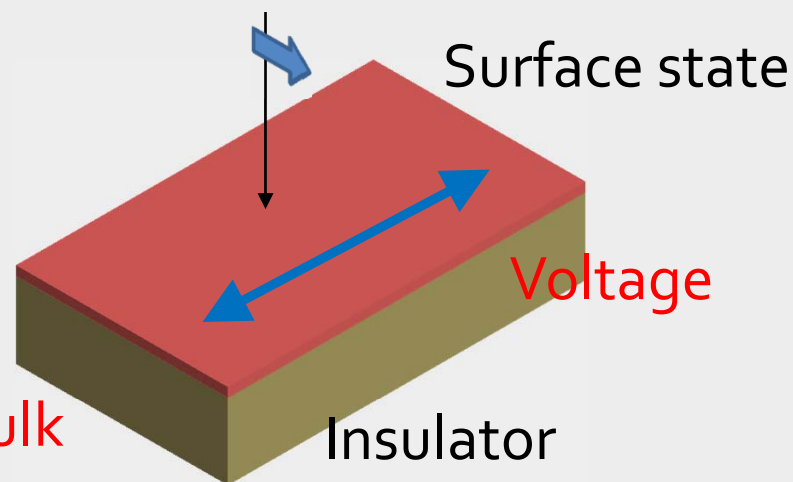
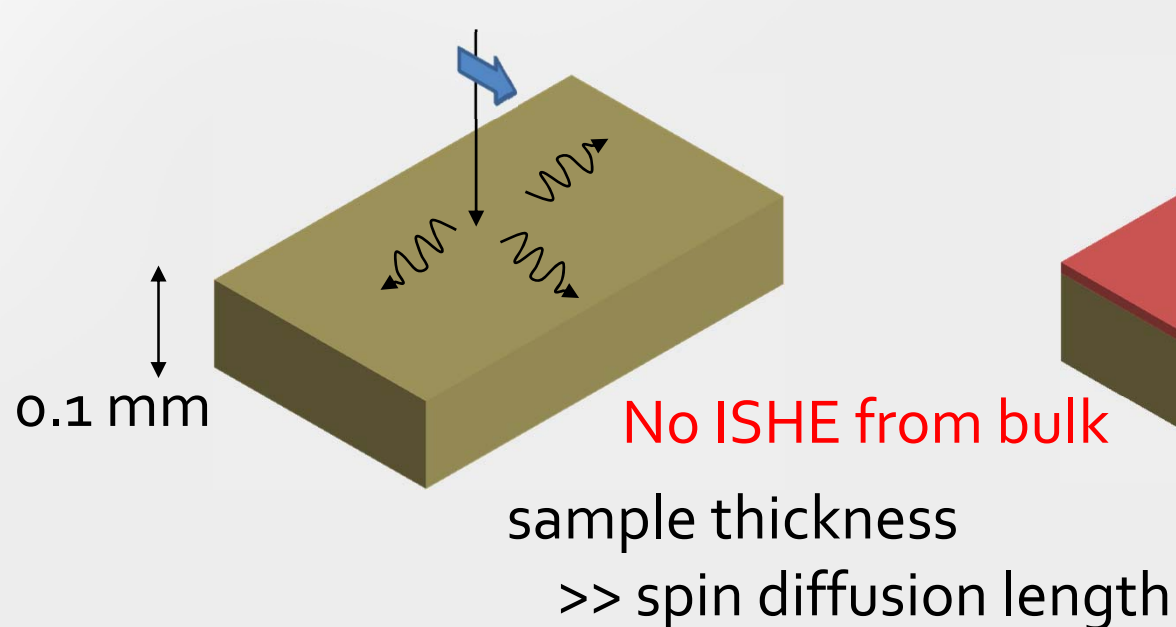
A.A.Taskin, et al. PRL 107, 016801 (2011)



Bulk-metallic TIs:

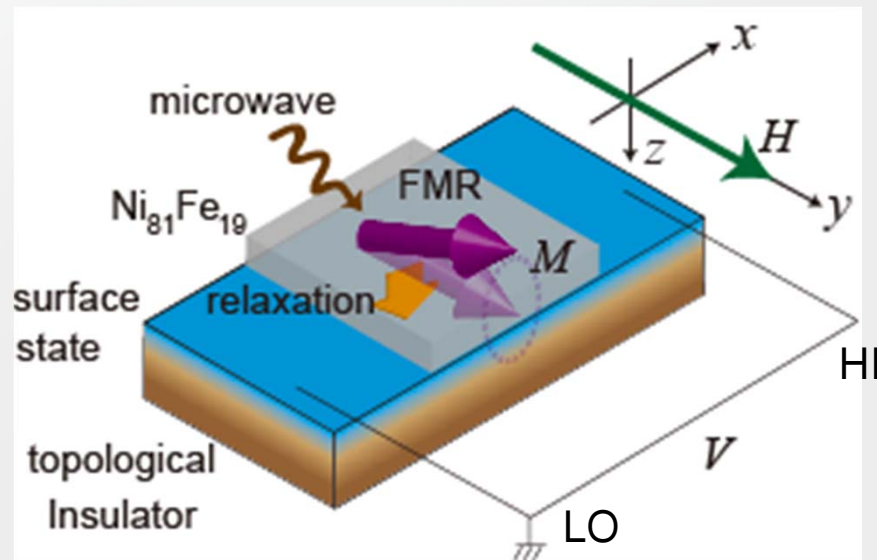
Bi_2Se_3

From Yoichi Ando
(Osaka Univ.)

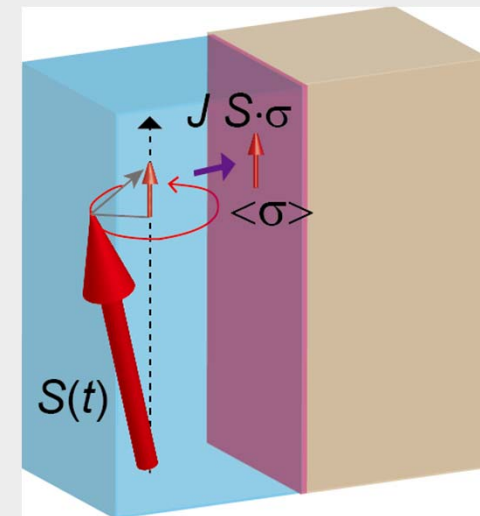


Methods and samples

- ferromagnet : permalloy ($\text{Ni}_{81}\text{Fe}_{19}$) 20nm thick
- coplanar-type wave guide, network analyser (typically, 5 GHz is used)
- measurement down to 15K (probe station)



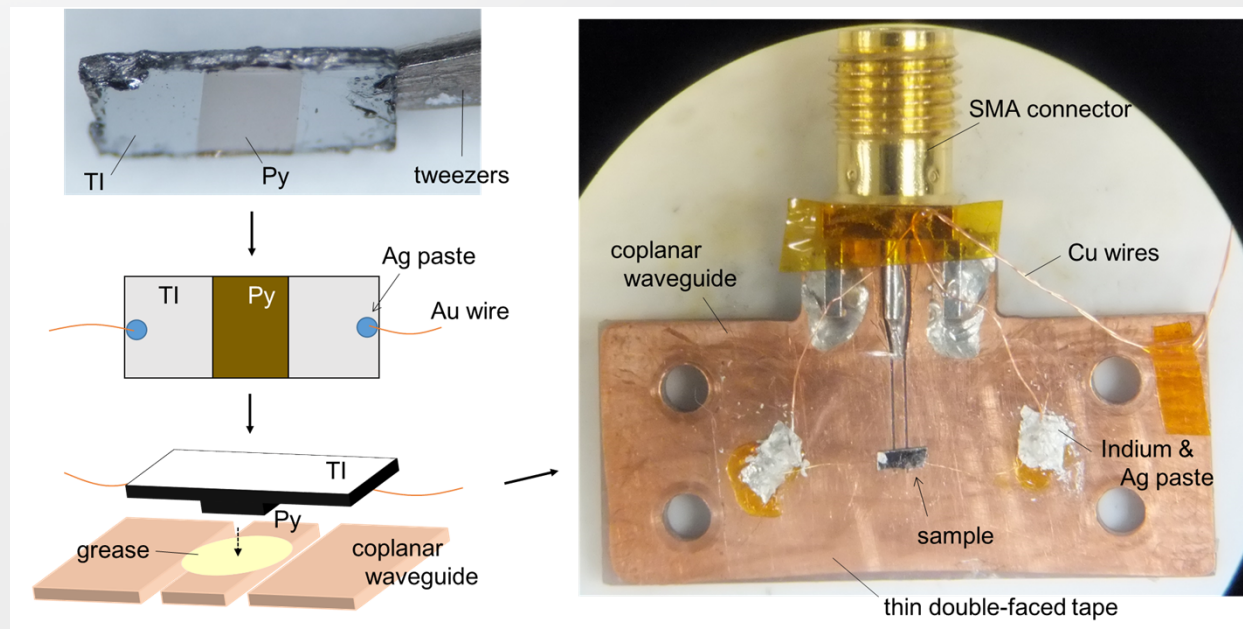
Spin pumping



spin precession
 $\Rightarrow$ spin current

Methods and samples

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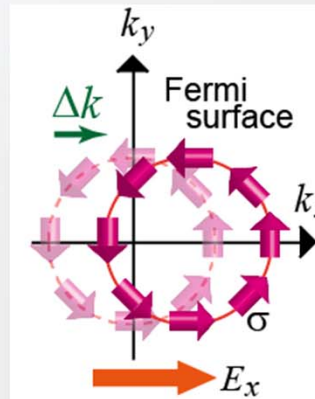
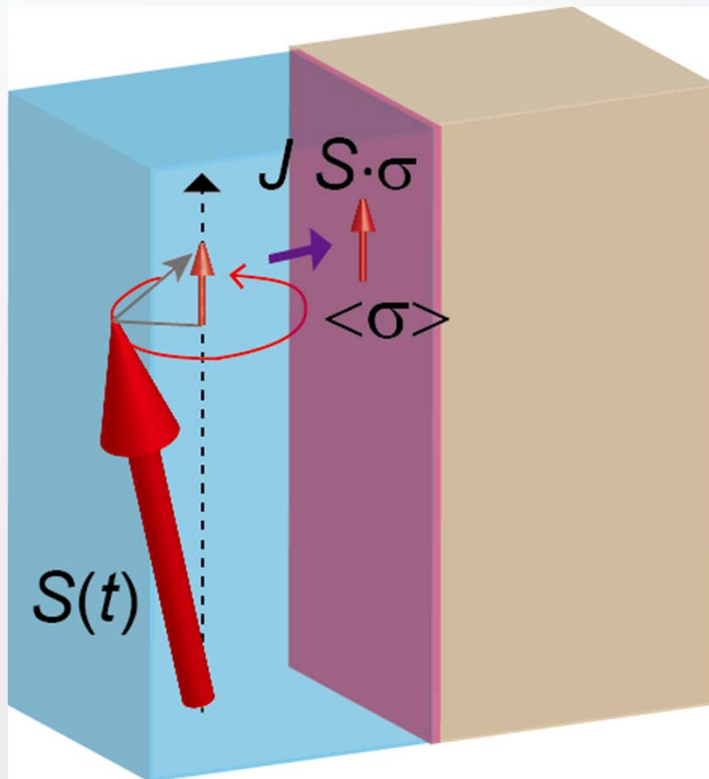


Spin pumping

Prof. Kentaro Nomura

$$H = v_F (\hat{z} \times \vec{\sigma}) \cdot \vec{p} + \underline{J_{sd} \vec{S} \cdot \vec{\sigma}} = v_F (\hat{z} \times \vec{\sigma}) \cdot (\underline{\vec{p} + e\vec{a}}) + \underline{J_{sd} S_z \sigma_z}$$

Spin pumping



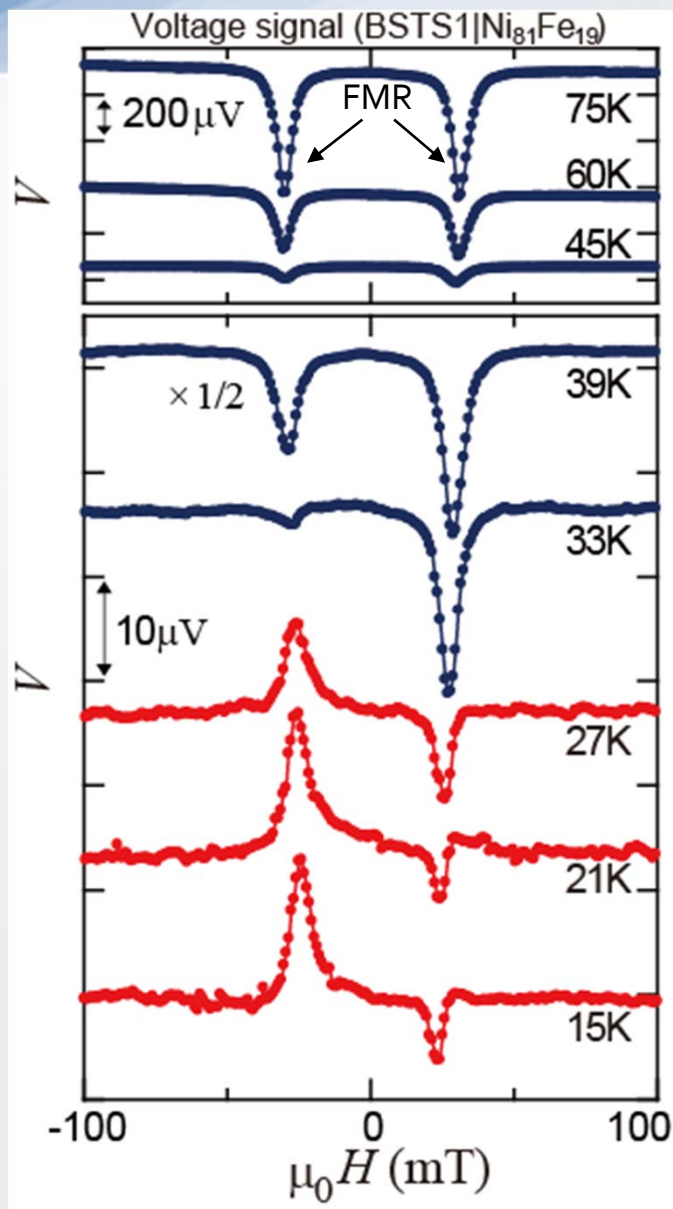
$\dot{\vec{a}}$ = voltage generation

spin exchange interaction
= torque

$$\vec{T}_{surface} = \gamma \vec{M} \times J_{eff} \langle \vec{\sigma} \rangle$$

damping enhancement

Voltage signals at FMR of Py at various temperatures for a $\text{Bi}_{1.5}\text{Sb}_{0.5}\text{Te}_{1.7}\text{Se}_{1.3}$ (BSTS) sample

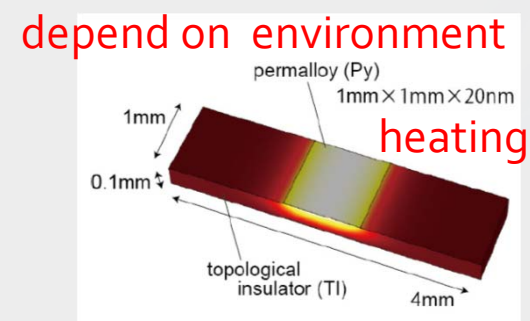


High-T : symmetric signal
(Seebeck effect)

Asymmetric signal

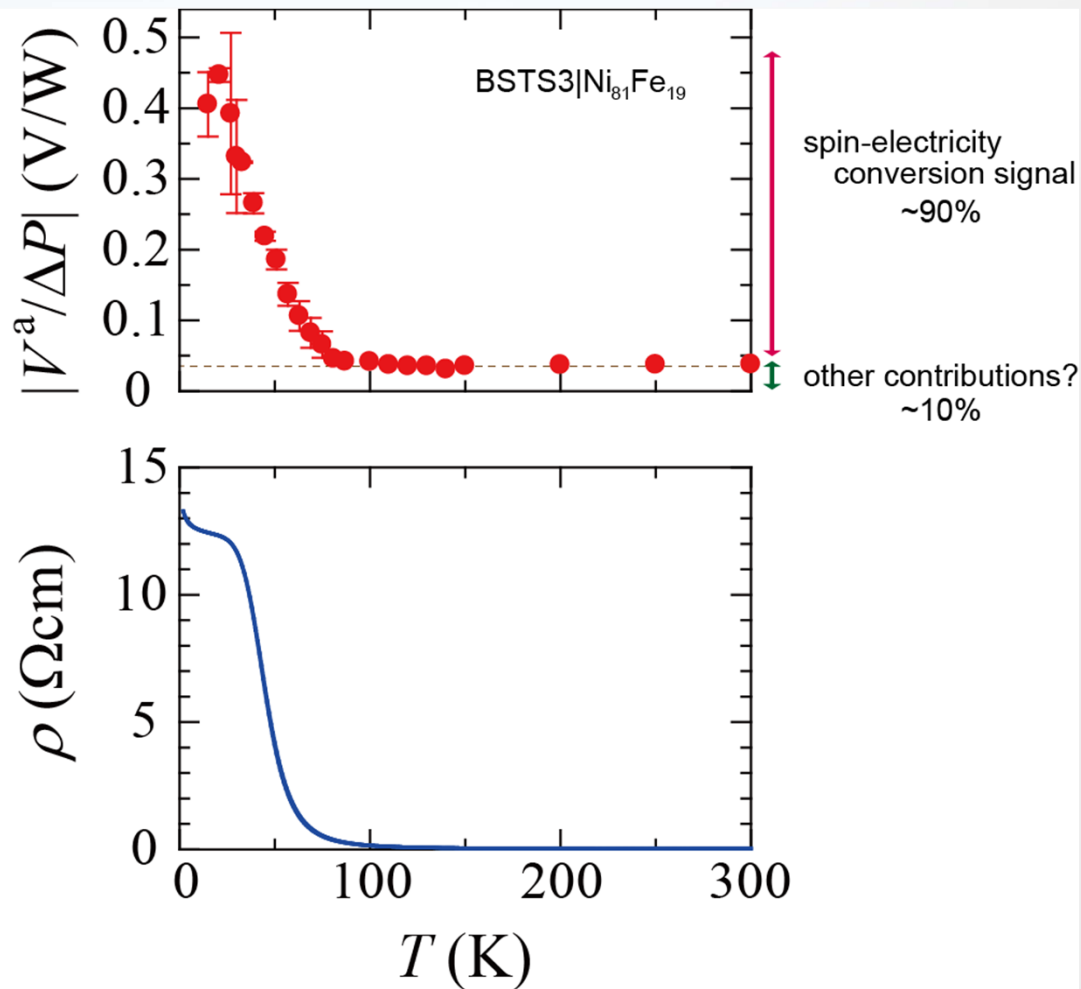
Sign inversion between +H and -H

Correlation to surface conduction
being dominant at low T_s



Correlation between antisymmetric voltage signals and surface transport

$$V^a = [V(H) - V(-H)]/2$$



V^a increases with decreasing T

↗ $\times 10 !!$

- NOT shunting of AMR

$$\frac{R_{\text{BSTS}}}{R_{\text{Py}} + R_{\text{BSTS}}} V_{\text{AMR}} \quad \nearrow \times 2$$

$$R_{\text{BSTS}} \approx R_{\text{py}} (\approx 5\Omega) \text{ at } 300 \text{ K}$$

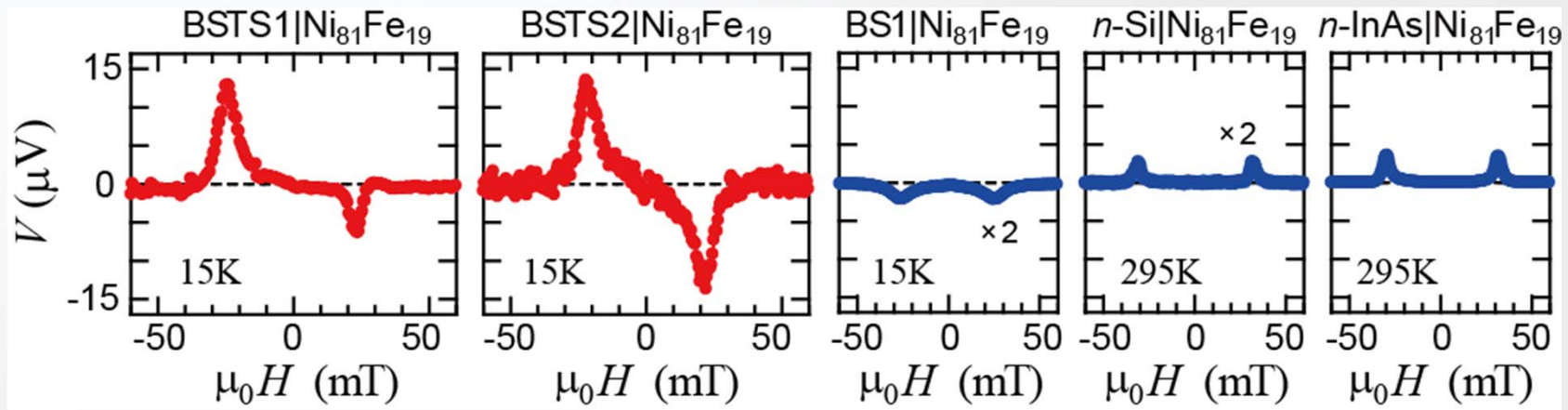
$$R_{\text{BSTS}} \gg R_{\text{py}} \text{ at low } T\text{s}$$

- NOT Nernst effect

$$\propto T \text{ at low } T\text{s}$$

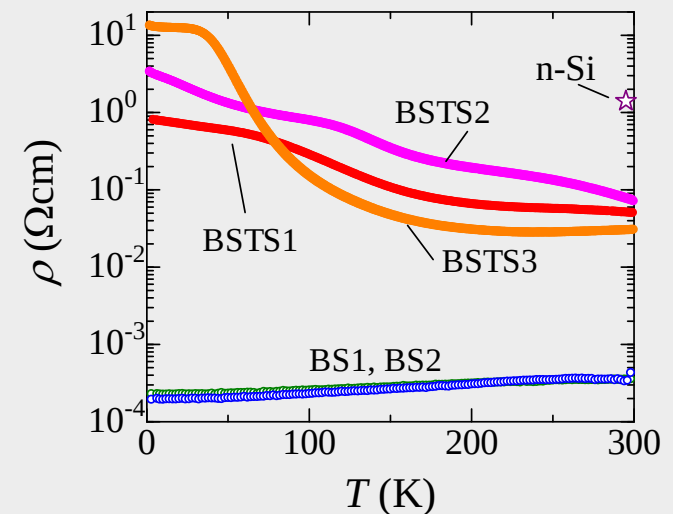
(Mott relation)

NO antisymmetric signal in control samples:
bulk-metallic TIs (Bi_2Se_3); conventional semiconductors



- Reproducible for all BSTS samples
- not observed for BS1, $n\text{-Si}$, or $n\text{-InAs}$

Anti-symmetric signals arise
on topological surface states

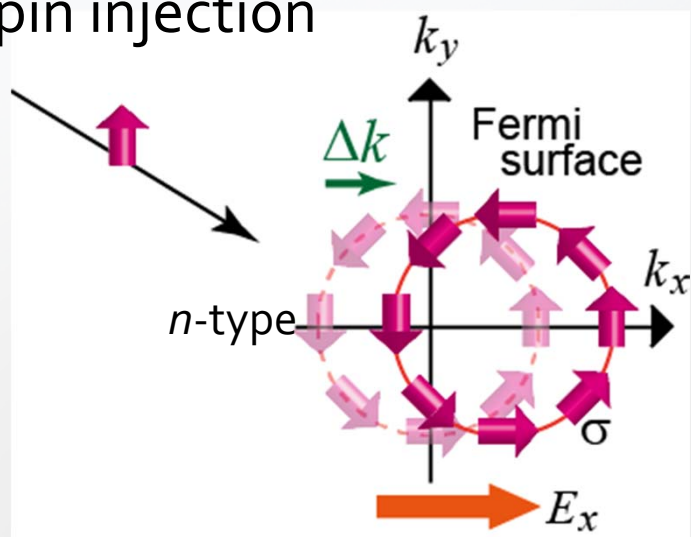


Mechanism of spin-electricity conversion effect

Prof. Kentaro Nomura

“spin-momentum locking” $\Rightarrow$ spin-electricity conversion

spin injection



shift of the Fermi circle

$$\Delta k_x = (e\tau / \hbar) E_x$$

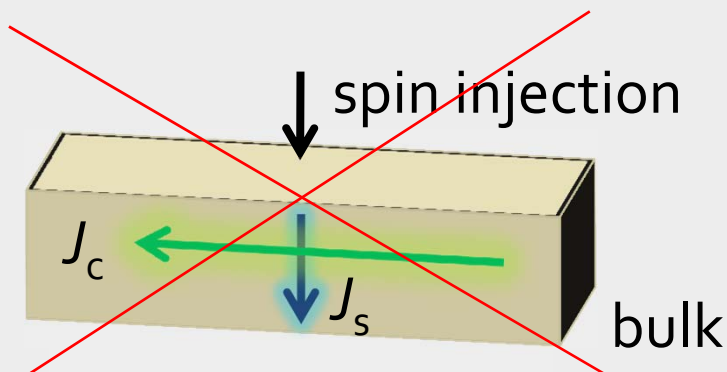
$$\frac{\langle \sigma_y \rangle}{A} = \frac{1}{A} \sum_{\vec{k}} f_{\vec{k}} \langle \vec{k}, + | \hat{\sigma}_y | \vec{k}, + \rangle$$



$$E_x = - \frac{4\pi\hbar}{e\tau k_F} \frac{\langle \sigma_y \rangle}{A}$$

same sign as the experiment

ISHE



if Hall angle θ defined, $\theta \sim 1\%$

Summary & perspective

Phys.Rev.Lett. **113**, 196601 (2014)

- observation of anti-symmetric signals on
millimeter-thick bulk-insulating TIs
- anti-symmetric signals arise on surface states
- build a model : new spin-electricity conversion
the voltage sign is consistent
in principle, high efficiency up to 100%, but only ~ 1% now.

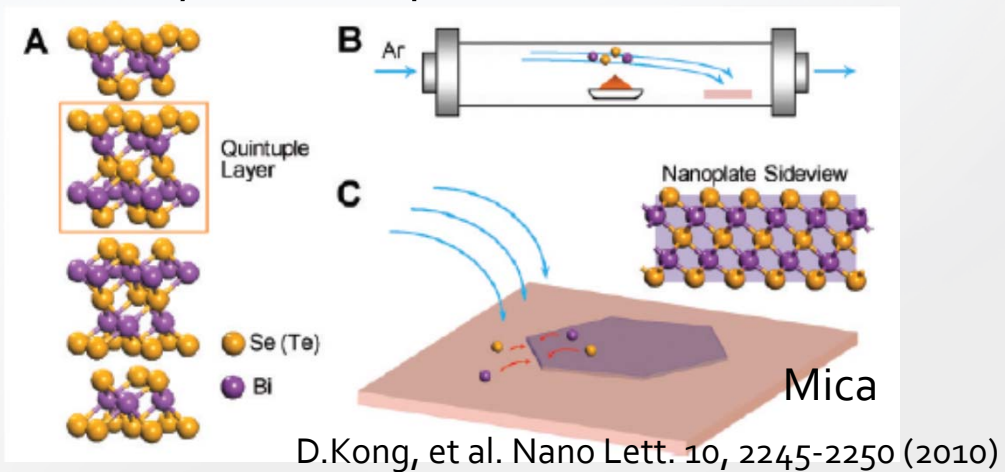


- improve the efficiency
(improve interface quality, reduce magnetic proximity effect, etc.)
- experiments in BSTS|YIG systems

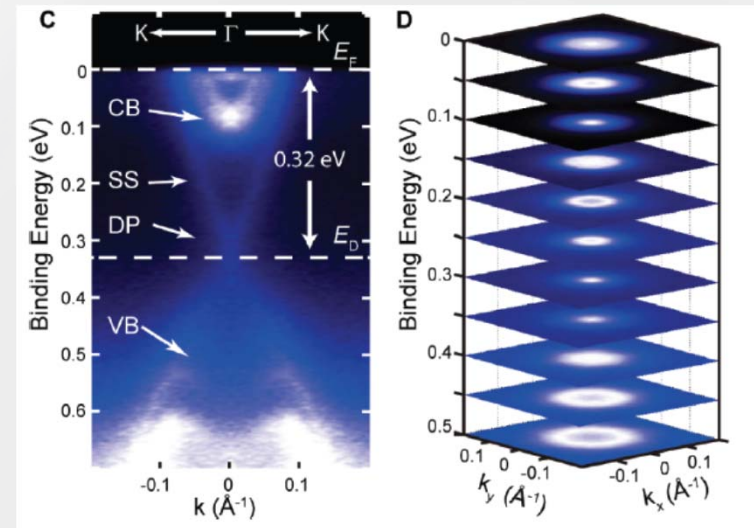
Perspective: BSTS on YIG

Growth of BSTS plates on Mica substrate $\Rightarrow$ transfer onto YIG

Catalyst-free vapor solid method



H.Li, et al. JACS. 134, 6132-6135 (2012)



BSTS plate (~ 1mm size)

$\Rightarrow$ transfer onto YIG

By Dr. Tanabe (Tohoku Univ.)



Au(20nm)|YIG

$\text{Bi}_{1.5}\text{Sb}_{0.5}\text{Te}_{1.7}\text{Se}_{1.3}$ plate
(50 nm thick)

